Dodecaindane (tBu₃Si)₈In₁₂—A Compound with an In₁₂ Deltapolyhedron Framework**

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Dedicated to Professor Helmut Werner on the occasion of his 65th birthday

We recently reported that the thermolysis of tetrasupersilyldialane $R_2^*Al-AlR_2^*$ ("supersilyl" $R^*=$ tri-tert-butylsilyl) in heptane at $100\,^{\circ}$ C initially gives trisupersilyldialanyl $R_3^*Al_2$, which is metastable at room temperature, and then leads to the red-violet tetrasupersilyl-tetrahedro-tetraalane $\mathbf{1a}^{[1]}$. Analogously, trisupersilyldigallanyl $R_3^*Ga_2$ thermolyzes in heptane at $100\,^{\circ}$ C to give the deep violet tetrasupersilyltetrahedro-tetragallane $\mathbf{1b}^{[2]}$. The enlargements of the element

$$R^* = SitBu_3$$

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$$1a: E = AI$$

$$1b: E = Ga$$

$$1c: E = In$$

clusters according to Equations (1), and (2), accordingly are initiated by thermal dissociations of element – supersilyl bonds, which in the case of the digallane R₂*Ga–GaR₂* are so facile that so far instead of

 $R_4^*Ga_2$ only the supersilyl-poorer $R_3^*Ga_2$ compound could be isolated. [3] The resulting supersilyl radicals R^* dimerize $\it quickly$ to give "superdisilane" R^*-R^* [Eq. (3)], which is $\it slowly$ converted at 100 °C in heptane into "supersilane" R^*-H by H-uptake. [4]

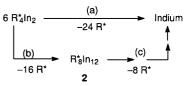
$$2R_4^*Al_2 \rightarrow R_4^*Al_4 + 4R^*$$
 (1)

$$2R_3^*Ga_2 \rightarrow R_4^*Ga_4 + 2R^*$$
 (2)

$$R^*-R^* \rightleftharpoons 2R^* (+2H \rightarrow 2R^*-H) \tag{3}$$

As a continuation of our studies we set out to synthesize tetrasupersilyl-tetrahedro-tetraindane $\mathbf{1c}$ as a further indate-trahedrane in addition to the two known tetraorganyl-tetrahedro-tetraindanes R_4In_4 ($R=C(SiMe_3)_3$ and $C(Si-Me_2Et)_3^{[6]}$) by thermolysis of tetrasupersilyldiindane $R_2^*In-InR_2^*$. The diindane in question, which is readily accessible from $InCl_3$ and R^*Na in THF (see Experimental Section), indeed completely thermolyzes in boiling heptane (ca. $100\,^{\circ}C$) after 22 h to give supersilane R^*H and an indium-containing product. From the dark reaction solution blackviolet, water- and air-sensitive crystals precipitate at room temperature in the course of days after substituting benzene for the heptane. These crystals are thermally comparably stable and are almost insoluble in heptane, benzene, or

toluene even at $100\,^{\circ}\text{C}$. Surprisingly, according to X-ray structural analyses^[7] these crystals are not of 1c but of octasupersilyldodecaindane 2. Thus, thermolysis of the diindane $R_4^*\text{In}_2$ at $100\,^{\circ}\text{C}$ is accompanied by elimination of more supersilyl radicals than that of the dialane $R_4^*\text{Al}_2$ or that of the digallanyl $R_3^*\text{Ga}_2$. Consequently the former case leads to a more pronounced enlargement of the element cluster than the latter two. In other words, the thermal decomposition of the diindane, which finally leads to indium (Scheme 1, Reaction (a)), initially stops at an element-richer cluster level (Scheme 1, Reaction (b)) than that of the dialane or that of the digallanyl.



Scheme 1. Thermal cluster enlargements starting from $R_4^*In_2$ ($R^* = SitBu_3$).

Figure 1 shows the X-ray crystal structure of **2** (local symmetry approximately S_4), in which all H atoms have been omitted for clarity. It reveals a closed polyhedron framework of 20 triangular faces and 12 In atoms, which does not exhibit a spherical form, such as the icosahedrally shaped $B_{12}H_{12}^{2-}$, [8] but

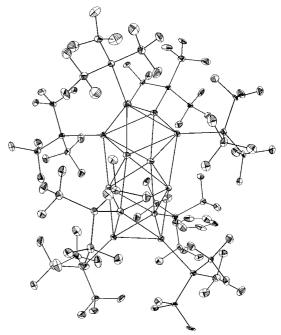


Figure 1. View of the crystal structure of $R_8^* In_{12}$ (ORTEP plot, 25% thermal probability ellipsoids, hydrogen atoms are omitted for clarity).

resembles a stretched ellipsoid. The four In atoms at the ends of the ellipsoid each carry one supersilyl group and the four In atoms in the middle of the ellipsoid carry no supersilyl group. The four spherical SitBu₃ groups at the end of the ellipsoid display distorted-tetrahedral packing. This illustrates the tendency (attributed to van der Waals interactions^[4]) of the

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supersilyl groups to form the densest possible packing arrangement. The arrangement of the In atoms at the ends of the In $_{12}$ cluster has to "submit" to this tendency. The SitBu $_3$ groups play a structure-determining role in the structure of the In $_{12}$ cluster, which can be described as a section of elemental indium (distorted cubic closest packing^[8, 9]). The longitudinal diameter of the In $_{12}$ cluster is about 750 pm. Thus cluster **2**, which is formed in the course of the thermolysis (b), approaches the realm of nanostructured materials; this area is then passed through in the course of the thermolysis (c) (Scheme 1), which has still to be studied in detail.

The presentation of the In_{12} polyhedron shown in Figure 2 gives a better insight into the present structures. The In_{12} cluster consists of two distorted octahedral In_6 building blocks, which when considered as separate entities can be classified as

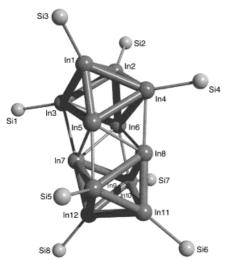


Figure 2. View of the crystal structure of $R_8^* In_{12}$, which is divided into two $R_4^* In_6$ octahedra, and atom numbering system used (local symmetry approximately S_4 ; SCHAKAL plot; atoms with arbitrary radii; tBu groups are omitted for clarity). Selected bond lengths [Å] and angles [°] (in each case only one distance and angle are given for one set of bond and angles; however, the underlying S_4 symmetry is merely an approximation): In1-In2 3.091(2), In1 - In3 2.948(1), In1 - In4 3.173(2), In1 - In5 2.814(2), In3 -In5 3.191(1) (the equivalent distances In4-In6/In7-In10/In9-In12 are 3.192(2)/3.267(1)/3.307(2)), In3-In6 3.141(2), In3-In7 3.037(2), In5-In7 3.004(1), In5-In8 3.009(1), In5-In9 3.059(2), In1-Si3 2.668(3), In3-Si1 2.685(3), Si - C (mean) 1.94; In5-In1-In3 67.21(3), In5-In1-In2 94.41(3), In3-In1-In4 93.40(5), In3-In1-In2 64.06(3), In5-In1-In4 62.49(3), In2-In1-In4 55.81(3), In1-In3-In7 111.63(4), In1-In3-In6 90.82(4), In7-In3-In5 57.62(3), In7-In3-In2 109.25(4), In5-In3-In2 85.37(4), In7-In3-In6 58.32(3), In1-In3-In5 54.38(3), In6-In3-In5 68.73(4), In1-In3-In2 60.13(4), In1-In5-In7 116.62(4), In7-In5-In8 72.42(4), In7-In5-In9 61.59(3), In1-In5-In4 64.41(3), In1-In5-In8 121.77(4), In1-In5-In9 173.68(4), In8-In5-In9 64.07(3), In7-In5-In4 109.27(4), In8-In5-In4 59.06(4). In1-In5-In3 In8-In5-In3 107.68(4), In4-In5-In3 89.87(4). In9-In5-In4 121.84(4), In7-In5-In3 58.61(4), In9-In5-In3 118.73(4), Si3-In1-In2 135.62(7), Si1-In3-In1 136.22(8), C-Si-C (mean) 111.3.

closo compounds.^[10] Thus, the dodecaindane **2** can be described as a *conjuncto* indane (cf. the boron hydride $B_{20}H_{16}^{[8]}$). Therefore it seems possible that **2** is formed from the diindane $R_4^*In_2$ via hexaindane as an intermediate product $R_4^*In_6$, which dimerizes to give the dodecaindane **2**. Indeed, in the synthesis described above insoluble **2** is formed from a soluble precursor, which is initially detectable in the reaction mixture, and which we are currently trying to isolate.^[11]

The In–In distances in **2** range from almost 2.80 to 3.30 Å. On average they are shorter than the In–In bond lengths in indium metal and longer than those in other low-valent uncharged indium compounds (Table 1). The In–In distances differ slightly within the two In₆ clusters; in contrast, the In–In distances between the two In₆ octahedra are both about

Table 1. Bond lengths d(In-In) in indium metal and in several uncharged indium compounds $(\text{Dsi} = \text{CH}(\text{SiMe}_3)_2, \text{Tsi} = \text{C}(\text{SiMe}_3)_3, \text{Tip} = 2,4,6-iPr_3C_6H_2, R* = \text{SitBu}_3).$

Compound	d(In-In) [Å]	Ref.
In metal	3.252/3.377	[9]
Dsi_4In_2	2.828(1)	[12]
Tip_4In_2	2.775(2)	[13]
$R_4^*In_2$	2.922(1)	[5]
$(Tip_2In)_3In$	2.696(2)	[13]
Tsi ₄ In ₄	3.002(1)	[6]
$R_8^*In_{12}$	2.80 - 3.30	this work

3.00 Å. The Si–In distances of about 2.68 Å are shorter than those in the diindane $R_4^* In_2$ (ca. 2.78 Å^[5]), which indicates that the supersilyl groups in the dodecaindane sterically inhibit one another less than in the diindane. The same tendency is indicated by the Si–C distances and the C-Si-C angles of the supersilyl groups, which are on average 1.94 Å and 111.3° , and lie in the normal range of 1.94-1.95 Å and $110-112^{\circ[4]}$ (cf. $R_4^* In_2$: 1.95 Å and $109.7^{\circ[5]}$).

To date there are only a few donor-free, uncharged molecular compounds with clusters from boron homologues (cf. ref. [5]). In the case of indium, these include diindanes R_4In_2 with In_2 frameworks (cf. among others ref. [5, 12, 13] and Table 1), the tetraindanes (Tip₂In)₃In with an acyclic In₃In framework (cf. ref. [13] and Table 1), and tetraindanes R_4In_4 with a tetrahedral In_4 framework (cf. ref. [6] and Table 1). The In–In interactions are only very weak (cf. ref. [5]; $Cp^*=C_5Me_5$; $Cp^{**}=C_5(CH_2Ph)_5$) in the compounds (Cp^*In)₆ and (Cp^*In)₂. The *conjuncto*- R_8^*In ₁₂ compound represents a unique E_{12} polyhedron structure for boron and its homologues and will naturally stimulate the search for compound homologues R_8E_{12} (E=B, Al, Ga, Tl) as well as for other donor-free and uncharged polyhedral compounds $R_{< n}E_n$ of the boron homologues.

According to the space-filling model the surface of the central In_{12} cluster of $R_8^*In_{12}$ is almost completely covered by eight supersilyl groups. This probably plays a major role in determining the outcome of the thermolysis of $R_4^*In_2$. Owing to their smaller surface the corresponding Ga_{12} and Al_{12} polyhedra offer less space for eight supersilyl groups, thus compounds of the type $R_8^*Ga_{12}$ and $R_8^*Al_{12}$ should be more thermolabile than $R_8^*In_{12}$ or only accessible with sterically less demanding substituents such as iPr_3Si .

Experimental Section

 $R_4^* In_2$: $tBu_3 SiNa(THF)_2~(10.5~mmol)$ in THF (10 mL) was added dropwise to a suspension of InCl $_3~(0.778~g,~3.50~mmol)$ in THF (30 mL), which had been cooled to $-78\,^{\circ}C$. The reaction mixture was stirred for 20 h at $-78\,^{\circ}C$. On slowly allowing the mixture to warm to room temperature, the solution turned deep violet. The mixture was then stirred for 5 h at room temperature. According to the 1H NMR spectrum (C_6D_6) the solution

contained exclusively $R_4^* In_2$ and $R^{*-}R^{*}$ in the molar ratio 1:1 (2 InCl $_3+6\,R^*Na\to R_4^*In_2+R^{*-}R^*+6\,NaCl;$ identification of the products by comparison with authentic samples^{[2,5]}). After removal of all volatile components in an oil pump vacuum, the residue was taken up in toluene (80 mL), the insoluble components (NaCl) were filtered, and the filtrate was concentrated to 20 mL, deep violet $R_4^*In_2$ (1.12 g, 1.09 mmol; 63%) crystallized from the solution at $-23\,^{\circ}C.^{[5]}$

 $R_8^*In_{12}$: A solution of $R_4^*In_2$ (0.370 g, 0.360 mmol) in heptane (45 mL) was heated under reflux (ca. 100 °C) for 22 h. According to the ¹H, ¹³C{¹H}, and ²⁹Si NMR spectra of the reaction solution, the diindane completely decomposed after replacement of C_6D_6 for heptane, leading to supersilane tBu₃SiH (identified by comparison with authentic sample^[2]) and an indiumand supersilyl-containing product (two different types of SitBu₃ groups in the ratio 1:1); ¹H NMR: $\delta = 1.419$ and 1.271 (ratio of areas ca. 1:1); ¹³C{¹H} NMR: $\delta = 33.72/25.47$ and 32.60/26.59 (each CMe₃/CMe₃); ²⁹Si NMR: $\delta =$ 64.2 and 50.9). After removal of all volatile components in an oil pump vacuum, the residue was taken up in benzene (40 mL), and the solution was concentrated to 10 mL, $R_8^*In_{12}$ (0.05 g, 0.02 mmol; ca. 30%) crystallized from the solution in the course of a few days at room temperature. Crystals suitable for the X-ray structural analysis were grown from C₆D₆. They do not dissolve in heptane, benzene, or toluene, either at room temperature or at 95 °C (no NMR signals). Thus the original thermolysis solution evidently did not contain dodecaindane but precursors of this cluster, from which R₈*In₁₂ was formed.

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dimensions $0.02 \times 0.3 \times 0.4 \text{ mm}^3$. The crystal was mounted in perfluoro ether oil, T = 183(2) K, $C_{102}H_{216}D_6In_{12}Si_8$, $M_r = 3051.36$, blackviolet platelets, monoclinic, a = 18.329(7), b = 32.02(2), c =22.454(8) Å, $\beta = 97.74(1)^{\circ}$, V = 13059(10) Å³, Z = 4; space group $P2_1$ / n, $\rho_{\text{calcd}} = 1.552 \text{ Mg m}^{-3}$, $\mu = 2.185 \text{ mm}^{-1}$, F(000) = 6136. Data collection: 2θ from 2.98 to 49.42° , $-21 \le h \le 19$, $-37 \le k \le 37$, $-26 \le l \le 25$; of 64586 reflections, 18449 were independent and 11876 were observed $(F > 4\sigma(F))$, semiempirical absorption correction with SADABS (max./min. transmission 1.000/0.684), $R_1 = 0.0622$, $wR_2 =$ 0.1033 $(F > 4\sigma(F))$, GOF $(F^2) = 1.076$; maximum residual electron density 1.098 e ${\rm A}^{-3}$. The weighting factor was $w^{-1} = \sigma^2 F_{\rm o}^2 +$ $(0.0279 P)^2 + 53.5075 P$ with $P = (F_o^2 + 2F_c^2)/3$. The structure was solved by direct methods (SHELXTL, version 5). All non-hydrogen atoms were refined anisotropically. Hydrogen atoms were included in calculated positions and refined using fixed isotropic U_i values and a riding model. Crystallographic date (excluding structure factors) for the structure reported in this paper have been deposited with the Cambridge Crystallographic Data Centre as supplementary publication no. CCDC-112178. Copies of the data can be obtained free of charge on application to CCDC, 12 Union Road, Cambridge CB21EZ, UK (fax: (+44)1223-336-033; e-mail: deposit@ccdc.cam.

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- [10] If the four R*In groups each donate two electrons, and the two In atoms each donate three electrons or—more probably—each only one electron (inert s electron pair!) to the In₆ framework of 2, 14 = 2n+2 or 8 = 2n 2 framework electrons (n = number of framework atoms) can be calculated. According to the framework electron counting rules of Wade and Mingos^[8] in the first case R₄*In₆ should be classified as a closo compound (In₆ octahedron), in the latter case as a double-capped closo compound ("hypoprecloso" compound; double-capped In₄ tetrahedron).^[11] R₄*In₆ can be described as the supersilyl derivative of the closo-hexahydridohexaindate In₆H₆²⁻, which has two hydride ions less and is a homologue of the known closo-hexahydridohexaborate B.H₂^{2-[8]}
- [11] By employing R₆*In₈ we recently isolated an indane, which in terms of its framework electron number^[10] is related to R₄*In₆. According to the X-ray structural analysis in the structure of the present In₈ cluster (double-capped In₆ octahedron) the octaindane is rather classified as a hypoprecloso compound in accordance with the discussion in ref. [10]: N. Wiberg, T. Blank, H. Schnöckel, A. Purath, unpublished results.
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